

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S3	0	451/6.clas.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/09 11:10
S4	737	451/6.clcs.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/11/01 15:40
S5	166	S4 and image	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/09 11:11
S6	0	S4 and ("photo image sensor")	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/09 11:11
S7	14	S4 and ("image sensor")	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/09 11:11
S8	16	S4 and (slurry adj dispenses\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/09 11:22
S9	0	(slurry adj dispenses\$4) and (image adj sensor)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/09 11:22
S10	315	"451".clas. and (slurry adj3 (control or monitor or nozzle or by-pass))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/10 15:17
S12	0	("6814835").URPN.	USPAT	OR	OFF	2004/11/09 14:08
S15	0	("6802762").URPN.	USPAT	OR	OFF	2004/11/09 14:13
S16	6	("20020045412" "20020173232" "5799643" "6161533" "6406364" "6475070").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2004/11/09 16:55
S17	9	("4042444" "4805348" "5099614" "5329732" "5498196" "5498199" "5674410" "6001215" "6319099").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2004/11/09 16:54
S18	129	"438".clas. and (slurry adj3 (control or monitor or nozzle or by-pass))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/09 17:20

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S31	57277	"356".clas.	US-PGPUB; USPAT; USOCR	OR	OFF	2004/11/10 12:48	US-PGPUB; USPAT; USOCR	OR	OFF	2004/11/10 12:48
S32	518	356/335.ccls.	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 13:12	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 13:12
S33	112	S32 and density	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 12:53	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 12:53
S35	0	S32 and "photo image sensor"	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 12:54	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 12:54
S42	0	S32 and (photo adj image)	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 12:56	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 12:56
S43	135	S32 and fluid\$	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 13:07	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 13:07
S52	13	(356/335.ccls.) and slurry	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 13:47	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 13:47
S54	20	photo image sensor	US-PGPUB; USPAT; EPO; JPO; DERVENT	ADJ	OFF	2004/11/10 13:53	US-PGPUB; USPAT; EPO; JPO; DERVENT	ADJ	OFF	2004/11/10 13:53
S55	101	"451".clas. and (nozzle and (bypass or by-pass))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 15:20	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 15:20
S59	129	"438".clas. and (slurry adj3 (control or monitor or nozzle or by-pass))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:21	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:21
S60	272	"438".clas. and (slurry and (control and monitor and nozzle and by-pass))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:22	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:22
S61	0	"438".clas. and (slurry and (control and monitor and nozzle and by-pass))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:22	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:22

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S62	0	"438".clas. and (slurry and (control and nozzle and by-pass))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:23	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:23
S63	203	"438".clas. and (slurry and (control and nozzle))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:23	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:23
S64	35	"438".clas. and (slurry same (control and nozzle))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 09:37	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 09:37
S65	4	"438".clas. and (slurry and (control and nozzle and bypass))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:23	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/10 17:23
S66	0	"438".clas. and (slurry same ((bypass or by-pass) and nozzle))	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 09:37	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 09:37
S67	29	("3187627" "3225193" "3819278" "3867033" "3975084" "4385830" "442642" "4523306" "4555179" "4613210" "463511" "4661845" "4664513" "4672437" "4769876" "4802761" "4804268" "4973561") PN OR ("5191388"),URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2004/11/12 11:01	US-PGPUB; USPAT; USOCR	OR	OFF	2004/11/12 11:01
S68	107	"451".clas. and (flow with control) same (density or size)	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 11:02	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 11:02
S69	21	"451".clas. and (flow with control) same density	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 15:39	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 15:39
S70	605	"451".clas. and (flow with control) and nozzle	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 14:08	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 14:08
S71	738	451/6.ccls.	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 11:41	US-PGPUB; USPAT; EPO; JPO; DERVENT	OR	OFF	2004/11/12 11:41

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S72	166	S71 and (density or ((particle or particals) adj3 size))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 11:45	
S73	2	S72 and (bypass or by-pass)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 11:42	
S74	132	S72 and slurry	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 12:06	
S75	131	(flow adj control) same ((particle adj size\$) and (density or composition))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 12:07	
S76	23	S75 and slurry	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 12:07	
S77	605	"451".das. and (flow with control) and nozzle	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 14:09	
S78	255	S77 and (sensor or detector or monitor)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 14:16	
S79	27	CMP and ((flow adj3 control) same (sensor or detector or monitor) and nozzle)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 14:19	
S81	28	(451/6.ccls.) and ((particle\$ or particals\$ adj size))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 15:12	
S84	6	(451/6.ccls.) and ((flow with control) same nozzle)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/12 15:41	
S85	2	"5710069".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/15 13:49	
S86	2	"6347976".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2004/11/15 14:49	

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S96	825	451/6.ccds.	US-PGPUB; OR	OFF	2005/11/01 15:40
S97	17	S96 and (diluent dilutant diluent mitigate (thin adj out) (water adj down))	US-PGPUB; OR	OFF	2005/11/01 15:53
S98	0	("2004/0014396").URPN.	US-PGPUB; OR	OFF	2005/11/01 15:44
S99	25	S96 and (diluent dilutant diluent mitigate (thin adj out) (water adj down))	US-PGPUB; OR	OFF	2006/05/23 09:17
S10 0	9	S99 not S97	US-PGPUB; OR	OFF	2005/11/01 15:59
S10 1	2	0986988.app.	US-PGPUB; OR	OFF	2005/11/01 15:59
S10 2	1	10/676643.app.	US-PGPUB; OR	OFF	2005/11/01 17:06
S10 3	876	451/6.ccds.	US-PGPUB; OR	OFF	2006/05/23 09:17
S10 4	3	S103 and (dilu\$6 with (particle particles partial))	US-PGPUB; OR	OFF	2006/05/23 09:18
S10 5	280	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 with (particle particles partial))	US-PGPUB; OR	OFF	2006/05/23 12:14
S10 6	192	(slurry and (CMP "Chemical mechanical planarizing")) and (dilu\$6 near8 (particle particles partial))	US-PGPUB; OR	OFF	2006/05/23 09:19

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S10 7	162	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 near6 (particle particles partial))	US-PGPUB; OR	OFF	2006/05/23 09:19
S10 8	116	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 near4 (particle particles partial))	US-PGPUB; OR	OFF	2006/05/24 09:18
S10 9	1	10/676643.app.	US-PGPUB; OR	OFF	2006/05/23 11:30
S11 0	66	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 with (abrasive near2 (particle particles partial)))	US-PGPUB; OR	OFF	2006/05/23 12:15
S11 1	116	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 near4 (particle particles partial))	US-PGPUB; OR	OFF	2006/05/24 09:21
S11 2	48	S111 and solvent	US-PGPUB; OR	OFF	2006/05/24 09:18
S11 3	6	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 near4 (particle particles partial)) with solvent\$2)	US-PGPUB; OR	OFF	2006/05/24 09:24
S11 4	165	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 near4 solvent\$2)	US-PGPUB; OR	OFF	2006/05/24 13:32
S11 5	26	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 near4 solvent\$2) and (sensor sensors)	US-PGPUB; OR	OFF	2006/05/24 09:27
S11 6	279	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 near solution)	US-PGPUB; OR	OFF	2006/05/24 13:33

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S11 7	116	(slurry and (CMP "Chemical mechanical polishing" "chemical mechanical planarizing")) and (dilu\$6 near solution) with water)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2006/05/24 13:33
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